

1968-2008

Docket No.: 283053US0PCT

**OBLON
SPIVAK**

ATTORNEYS AT LAW

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

RE: Application Serial No.: 10/560,527
Applicants: Haruo IWASAWA, et al.
Filing Date: December 13, 2005
For: SILANE POLYMER AND METHOD FOR FORMING
SILICON FILM
Group Art Unit: 1796
Examiner: MOORE, M.G.

SIR:

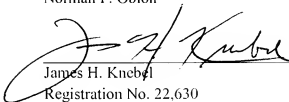
Attached hereto for filing are the following papers:

Response to the Requirement for Restriction

Our online credit card payment in the amount of **\$0.00** is being made covering any required fees. In the event any variance exists between the amount enclosed and the Patent Office charges for filing the above-noted documents, including any fees required under 37 C.F.R. 1.136 for any necessary Extension of Time to make the filing of the attached documents timely, please charge or credit the difference to our Deposit Account No. 15-0030. Further, if these papers are not considered timely filed, then a petition is hereby made under 37 C.F.R. 1.136 for the necessary extension of time.

Respectfully submitted,

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